# NANOCHEM® MiniSentry™ In-Line Purifier

### **Features and Benefits**

- Purification for point-of-use applications
- Highest Lifetimes
- Best Impurity Removal Efficiencies
  - Removes critical contaminants to sub parts-per-billion level (<0.1 ppb in inert gases)</li>
- Diffuson barrier at purifier inlet and outlet
  - Reduces media exposure to atmospheric air during purifier installation
- Enhances manufacturing process economy and improves equipment performance
- Provides consistently high purity gas under fluctuating inlet impurity conditions
- Improves component lifetime and reduces particle generation by removing moisture and volatile metals from corrosive gases
- Compact size for ease of installation
- No moving parts or power requirements
- · Does not require heating or cooling
- · Low overall cost of ownership

## **Specifications**

- Flow rates up to 1.0 slpm (0.06 NM³/hr)
- All metal parts, Type 316L stainless steel
- 0.003  $\mu m$  PALL Ultramet–L\* stainless steel particle filter with 99.999999% retention
- Outer diameter of 0.84 inches (21.5 mm) and total length of 3.31 inches (84.07 mm)
- Internal surface finish < 15 μin R<sub>a</sub>
- Maximum allowable working pressure of 3000 psig (21 MPa)
- Maximum operating temperature of 70°C

### Connections

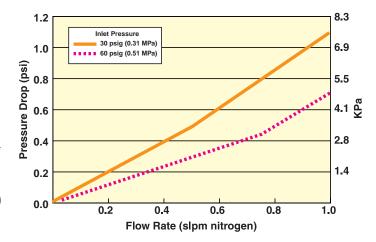
 Male inlet and outlet connections 1/4 inch, VCR®-compatible face seal fittings

## Overview

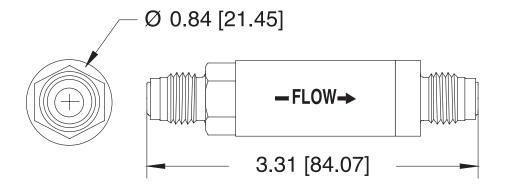
The NANOCHEM® MiniSentry™ Purifier is a compact purifier designed for placement internal to the process tool, delivering the gas purity required in a sub-micron fabrication environment.

This product is an in-line purifier for low-flow point-of-use applications, combining gas purification and particulate filtration in a footprint of only 3.31 inches (84 mm). NANOCHEM® purifiers provide insurance against virtually all process variables that cause contamination, including gas impurities introduced through the gas jungle. A typical location for this product would be directly before the process chamber or mass flow controller. The MiniSentry™ filter/purifier is a direct replacement for in-line particle filters.









All dimensions are in inches (mm)

Gas Type	Impurities Removed
Nitrogen (N₂), Argon (Ar), other inerts	< 0.1 ppb H <sub>2</sub> O, O <sub>2</sub> , CO <sub>2</sub> LDL
	< 1 ppb CO*
	< 0.1 ppb NMHC LDL
	$NO_x$ , $SO_x$ , $H_2S$
Ammonia (NH <sub>3</sub> )	< 0.1 ppb H <sub>2</sub> O, O <sub>2</sub> , CO <sub>2</sub> in inert gas LDL
	< 45 ppb H <sub>2</sub> O in ammonia LDL
Silane (SiH₄)	< 0.1 ppb H <sub>2</sub> O, O <sub>2</sub> , CO <sub>2</sub> LDL
	< 1 ppb CO*
	Chlorosilanes, disilane, siloxanes, arsine, phosphine
Hydrogen (H₂), Methane CH₄), Ethane (C₂H₀), other HC	< 0.1 ppb H <sub>2</sub> O, O <sub>2</sub> , CO <sub>2</sub> LDL
	< 1 ppb CO*
	$NO_{x}$ , $SO_{x}$ , $H_2S$
Sulfur Hexafluoride (SF <sub>6</sub> ), Carbon Tetrafluoride (CF <sub>4</sub> ),	< 0.1 ppb H <sub>2</sub> O, O <sub>2</sub> , CO <sub>2</sub> in inert gas LDL
other fluorocarbons	< 10 ppb O <sub>2</sub> , H <sub>2</sub> O in sulfur hexafluoride LDL
Oxygen (O <sub>2</sub> ), Carbon Dioxide (CO <sub>2</sub> ), Nitrous Oxide (N <sub>2</sub> O)	< 10 ppb H <sub>2</sub> O
Carbon Monoxide (CO)	Metal Carbonyls: Fe, Ni
Corrosives (HCI, HBr, CI <sub>2</sub> , SiH <sub>2</sub> CI <sub>2</sub> , SiHCI <sub>3</sub> , BCI <sub>3</sub> )	< 1 ppb H <sub>2</sub> O in inert gas
	< 100 ppb H <sub>2</sub> O in HBr LDL
	< 150 ppb H <sub>2</sub> O in HCl
	Volatile Metals: Fe, Mo, Cr, Ni, Mn, Ti

LDL – Lower Detection Limit by State-of-the-Art Analytical Instrumentation

NMHC – Non-methane Hydrocarbons

For a detailed list of purification media and impurities removed, refer to the Purification Media Table in NANOCHEM® Purification Solutions Brochure.

Specifications are subject to change.



<sup>\*</sup>NOTE: CO is removed efficiently by OMX & OMX-Plus™ media at low flow rates (recommend ¹/10 of normal flow rate)